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[19a-B32-1~2]8.8 Plasma Electronics Award Speech

Mineo Hiramatsu(Meijo Univ.)

Thu. Sep 19, 2019 9:30 AM - 10:30 AM B32 (B32)

△ : Presentation by Applicant for JSAP Young Scientists Presentation Award

▲ : English Presentation

▼ : Both of Above

No Mark : None of Above

10:00 AM - 10:30 AM

[19a-B32-2][Plasma Electronics Award Speech] Layer-by-layer etching of LaAlSiO_x

○Mitsuhiro Omura¹, Kazuhito Furumoto¹, Kazuhisa Matsuda¹, Toshiyuki Sasaki¹, Itsuko Sakai¹, Hisataka Hayashi¹ (1.Toshiba Memory)

Keywords:dry etching